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Free-volume extended defects in structurally-modified Ge-Ga-S/Se glasses

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Transformation of free-volume extended defects in selected chalcogenide glasses caused by thermal annealing for 10, 25 and 50 h were studied. For 80GeSe₂-20Ga₂Se₃ as well as for GeS₂-Ga₂S₃ glasses with different GeS₂ and Ga₂S₃ contents (80GeS₂–20Ga₂S₃, 82GeS₂–18Ga₂S₃, 84GeS₂–16Ga₂S₃) positron annihilation lifetime spectroscopy and Doppler broadening of annihilation radiation methods were applied. By analyzing the positron annihilation lifetime spectra decomposed into two components, it is shown that the observed changes in the second defect-related component for the 80GeSe₂-20Ga₂Se₃ glasses confirms the agglomeration of free volumes in the initial stage of annealing (10 h) with further fragmentation (25 h) and shrinkage (50 h). Increased content of Ge-related sub-system in the GeS₂-Ga₂S₃-based glasses results in the agglomeration of free-volume defects in the 82GeS₂–18Ga₂S₃ glasses with their further expansion in the 84GeS₂-16Ga₂S₃ matrix.

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1. Introduction

It is known that chalcogenide glasses (ChG) of Ge-Ga-S/Se systems have prospects for practical applications as optical modulators, fiber-optic amplifiers in the IR range, laser host materials, etc. [1-7]. Therefore, research of such materials is actively performed, in particular, studies of different atomistic imperfections such as free-volume extended defects like vacancies, clusters, voids, nanopores, cracks etc. [8,9]. These structural inhomogeneities have influence of the functional properties of ChG. Most researches focus on the study of structural [10-13], optical [14,15] and thermo-mechanical [16-19] properties of glasses. Nearest atomic arrangement in materials is studied with a variety of experimental measuring techniques including vibration and Raman scattering spectroscopy, XRD, SEM, XPS and other [20-23]. However, the selection of probes available to study defect-related free volumes is rather limited, especially at sub-nanometer scale. One of the best techniques capable to probe the finest free volumes is the positron annihilation lifetime (PAL) spectroscopy, the method grounded on physical phenomena of positron-electron interaction in a matter [24-26]. It is frequently used to identify spatial heterogeneities in crystals (dislocations, vacancy-like clusters and agglomerates etc.) [26,27], evolution of free volumes in organic polymers (size and number of open-volume holes, inner pores) [28,29], light metallic alloys (cracks, bubbles, etc.) [30], zeolites [31], gels [32], thick films [33], ceramics [34] but less commonly for network glasses.

On top of that, the positron annihilation technique in the measuring mode of Doppler broadening of annihilation radiation (DBAR) allows additional identification of dominant positron trapping sites in the tested objects. So, the combined PAL-DBAR measurements are expected to be useful to study defect-related void structure of solids affected by different structural inhomogeneities [35,36].

The PAL study of ChG in the Ge-Ga-S/Se-CsCl systems exposed by additional influence and changes of compositions were investigated in this work using two- and three-component fitting procedure of decomposition of PAL spectra [37-41]. In addition, we studied the influences of thermal annealing and composition of Ge-Ga-S/Se glasses on their microstructural properties, phase composition and optical properties [40,41]. The goal of this work is to study the evolution of defect-related extended free volumes in the 80GeSe₂–20Ga₂Se₃ ChG caused by thermal annealing as well as in the GeS₂–Ga₂S₃ glasses with

different amount of GeS₂ and GaS₃ (80GeS₂–20Ga₂S₃, 82GeS₂–18Ga₂S₃, 84GeS₂–16Ga₂S₃ glasses) using combined PAL and DBAR measuring tools.

2. Experimental

ChG of GeS₂-Ga₂S₃ and GeSe₂-Ga₂Se₃ compositions were prepared from melting mixture of highly pure raw materials (Ge, Ga, and S/Se: 99.999%) in the sealed silica ampoule kept under 10⁻⁶ Pa vacuum detailed described elsewhere [40,41]. The thermal annealing of the 80GeSe_2 - $20\text{Ga}_2\text{Se}_3$ ChG was performed at 380 °C for 10 h, 25 h and 50 h. The densities ρ were 4.352, 4.401, 4.472 and 4.454 g/cm³ for non-annealed 80GeSe₂-20Ga₂Se₃ glasses and annealed for 10, 25 and 50 h, respectively. The corresponding densities ρ of $80\text{GeS}_2-20\text{Ga}_2\text{S}_3$, 82GeS₂–18Ga₂S₃, 84GeS₂–16Ga₂S₃ glasses were 2.932, 2.905 and 2.896 g/cm³, respectively. The PAL spectra were performed with conventional ORTEC system of 230 ps resolution (the full width at half maximum FWHM of a single Gaussian determined by measuring 60Co isotope) at the temperature T = 22 °C and relative humidity RH = 35 %. Contribution intensity of source is 18 %. Two identical ChG samples were used to build a characteristic sandwich arrangement needed for PAL measurements. Each PAL spectrum had been measured with a channel width of 6.15 ps (with the number of channels set to 8000) and contained no less 10⁶ coincidences in total, which can be considered as conditions of improved measurement statistics. Isotope ²²Na of slow activity (~50 kBq) was used as source of positrons (prepared from of ²²NaCl, wrapped with Kapton foil (DuPontTM, Circleville, OH) of 12 µm thickness and sealed), which was sandwiched between two identical tested samples [40,41].

The measured PAL spectra of ChG were processed with standard LT computer program [42], in which the obtained curves were fitted by two non-fixed components (τ_I , τ_2 lifetimes and I_I , I_2 intensities). Therefore, the positron trapping modes in the studied ChG, such as average positron lifetimes τ_{av} , positron lifetime in defect-free bulk τ_b and positron trapping rate in defects κ_d were calculated using a formalism of two-states trapping model [43]. The (τ_2 - τ_b) difference was accepted as a size measure for extended free-volume defects where positrons are trapped (in terms of equivalent number of monovacancies), while τ_2/τ_b ratio was taken in a direct correlation to the nature of these defects [40]. The resulting inaccuracies in positron lifetimes τ and intensities I were ± 0.003 ns and ± 1 %, respectively, which led to ± 0.01 ns⁻¹ error-bar in positron trapping rate of defects κ_d .

DBAR measurements were performed using a Ge-detector with a resolution of 1.54 keV at 511 keV calibrated with set of standard sources (isotopes of ²¹⁴Pb and ²¹⁴Bi). Shape of 511

keV annihilation line was considered in terms of the so-called S and W parameters. The Sparameter (defined as a ratio in the central part to the total area of the annihilation line), characterizes the annihilation of positrons by low-momentum valence electrons that are sensitive to free volume defects. The W-parameter (defined as a ratio in the wing parts to the total area of the annihilation line) corresponds to the annihilation of positrons by highmomentum core electrons that are sensitive to the chemical environment at the annihilation site. For the DBAL spectrum the S-W parameterization energy range was selected from 502.29 to 519.71 keV ($\Delta S = 511 \pm 0.737$ keV, $\Delta W = 511 \pm [2.546 \div 6.36]$ keV), which corresponds to 260 measurement channels, giving thus an overall resolution of 0.067 keV per channel. Two independent measurements consisting of ~2×10⁶ counts were performed for each sample to reproduce the analyzed DBAL spectrum. The relative errors in S and Wparameters determined under such measuring protocol (when studied samples affected by different thermal treatments were removed from apparatus during measurement or principally different samples were probed) were determined to be 0.3 and 1.5 %, respectively. Since S parameter was chosen close to a reference value of ~0.5 in DBAL measurements, it could not be determined better accuracy than ± 0.0015 . The accuracy of determining the parameter W was ± 0.0002 .

3. Results and discussion

PAL spectrum for ChG on example of the basic 80GeSe₂-20Ga₂Se₃ glasses decomposed in two components is shown in **Figure 1**.

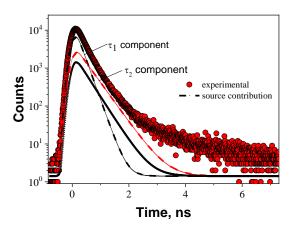


Figure 1. PAL spectrum for the basic 80GeSe₂-20Ga₂Se₃ ChG decomposed on two components

Dependences of lifetimes τ_1 and τ_2 as well as intensities I_1 and I_2 on the isothermal annealin duration of the 80GeSe_2 - $20\text{Ga}_2\text{Se}_3$ glasses are presented in **Figure 2**. As noted earlier [40],

two components in the fit of experimental PAL spectra can be obtained with reduced bulk positron lifetime τ_1 which itself has no physical meaning, positron lifetime in free-volume entities (positron traps) τ_2 and corresponding intensities I_1 and I_2 .

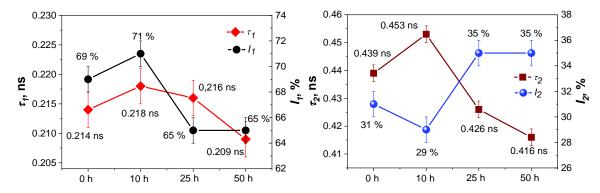
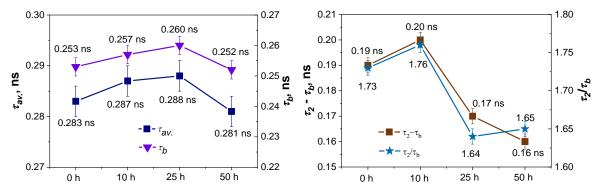


Figure 2. Dependences of lifetimes τ_1 and τ_2 as well as intensities I_1 and I_2 on annealing duration of the 80GeSe_2 - $20\text{Ga}_2\text{Se}_3$ glasses

Since (τ_1, I_1) component has no plausible physical meaning within accepted two-state positron trapping model, we will focus our further analysis on second defect-related (τ_2, I_2) component. As the annealing duration increases from the base 80GeSe_2 - $20\text{Ga}_2\text{Se}_3$ glass to the samples annealed for 10 h, the lifetime τ_2 goes up and the intensity drops, which indicates the agglomeration of voids in the material. As can be clearly seen from **Figure 3**, such tendencies lead to a decrease in positron trapping rate in defects κ_d .

However, both $\tau_{av.}$ and τ_b lifetimes remain practically unchanged (**Figure 3**). With a further increase in the duration of glass annealing to 25 h and up to 50 h, I_2 intensity begins to increase and the τ_2 lifetime decreases to 0.426 ns and 0.416 ns, respectively. Such changes lead to an increase in the κ_d . The other positron capture parameter, which is τ_2/τ_b ratio (describing the nature of defects) changes according to the parameters of the second component (**Figure 3**). However, the difference $(\tau_2 - \tau_b)$, which reflects the average size of defects where positrons are captured, naturally decreases during annealing.



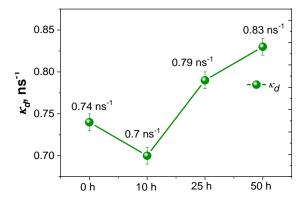


Figure 3. Dependences of positron trapping parameters on annealing duration of the 80GeSe₂-20Ga₂Se₃ glasses

As was shown in [40], during annealing the structure of glasses relaxes to a thermodynamically more favorable state (crystallization shrinkage or compaction occurs), thus eliminating the excess defect-related free volumes. Such changes indicate the disappearance of existing voids or their transformation into a larger number of smaller ones. In other words, it can be argued that the crystallization of the 80GeSe_2 - $20\text{Ga}_2\text{Se}_3$ glasses due to thermal annealing at 25 h leads to the appearance of small free-volume defects due to intensive fragmentation of larger ones. Such processes accompanied by a decrease in the τ_2 lifetime and a corresponding increase in the I_2 intensity are called fragmentation. Further annealing for 50 h results in shrinkage of fragmented free-volume defects. At that, the τ_2 lifetime continues to decline but I_2 intensity does not change. Schematically, the processes of transformation of free-volume defects in the 80GeSe_2 - $20\text{Ga}_2\text{Se}_3$ ChG during crystallization (annealing at different durations) are shown in **Figure 4**.

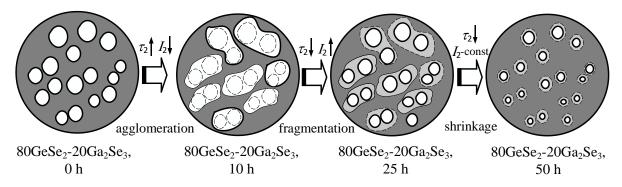


Figure 4. Processes transformation of free-volume defects in the 80GeSe₂-20Ga₂Se₃ ChG during annealing

In contrast to the positron trapping parameters of the second component of PAL spectra for the annealed 80GeSe_2 - $20\text{Ga}_2\text{Se}_3$ ChG, more pronounced are changes in the positron trapping rate in defects κ_d , especially with prolonged annealing (>25 h), when specific fragmentation shows a decrease in free-volume defects with a simultaneous increase of their amount (**Figure** 3). However, the ratio τ_2/τ_b is close to 1.7 for all samples independent of their annealing duration, indicating the same type of positron trapping centers.

PAL results are fairly consistent with the DRAL studies presented in the form of correlations of *S-W* parameters (**Figure 5**). All points on the dependence are grouped and located close to linear trajectory, which goes towards the direction of decreasing *S* and increasing *W* for nonannealed 80GeSe_2 - $20\text{Ga}_2\text{Se}_3$ glass and for the one annealed during 10 and 25 h. This behavior reflects a so-called normal trend in changing of *S-W* parameters in the κ_d - ρ correlation [44] and demonstrates the agglomeration of free-volume defects in the initial stages of thermal annealing of glasses for 10 h with future fragmentation in ChG annealed at 25 h. At increase of annealing duration for 50 h, the evolution of *S-W* parameters changes to the opposite trend (abnormal tendency in the κ_d - ρ correlation), which reflects the shrinkage defect-related free volumes.

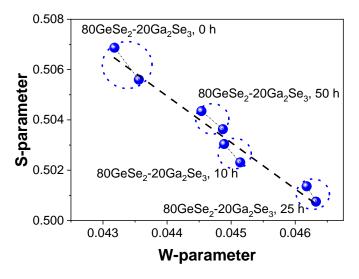


Figure 5. S-W plot for the basic and annealed 80GeSe₂-20Ga₂Se₃ ChG

The dependences of positron lifetimes τ_1 and τ_2 , intensities I_1 and I_2 obtained by decomposing of PAL spectrum into two components for basic GeS₂-Ga₂S₃ ChG with different content of GeS₂ and Ga₂S₃ are shown in **Figure 6**.

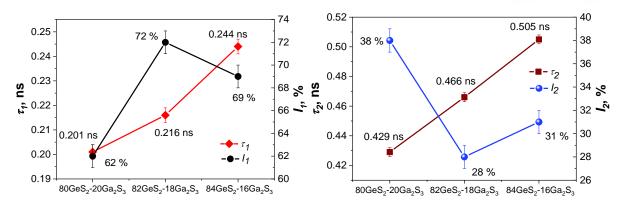


Figure 6. Dependences of lifetimes τ_1 and τ_2 , intensities I_1 and I_2 for the base GeS₂-Ga₂S₃ ChG

It can be seen that the lifetime of the second component τ_2 reflects a significant increase from 0.429 ns in the 80GeS_2 - $20\text{Ga}_2\text{S}_3$ ChG to 0.505 ns in the 84GeS_2 - $16\text{Ga}_2\text{S}_3$ glasses, while the I_2 intensity decreases from 0.38 to 0.28 and increases slightly to 0.31 (**Figure 6**). The change in the ChG composition from 80GeS_2 - $20\text{Ga}_2\text{S}_3$ to 82GeS_2 - $18\text{Ga}_2\text{S}_3$ leads to agglomeration of free-volume defects with their subsequent expansion in 84GeS_2 - $16\text{Ga}_2\text{S}_3$ glasses (**Figure 7**).

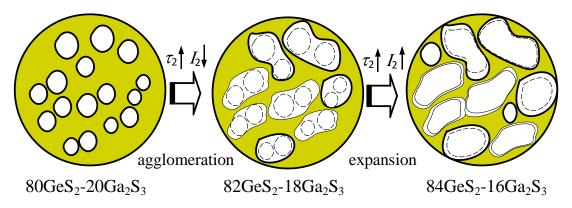


Figure 7. Transformation of free-volume defects in basic GeS₂-20Ga₂S₃ ChG

The observed changes in the positron trapping rate in defects κ_d are mainly associated with a decrease in the I_2 intensity (**Figure 8**). When the Ge- and Ga-containing components change, the role of internal structural states increases, and the value of κ_d parameter decreases to 0.66 ns⁻¹. Changes of the τ_b and τ_{av} lifetimes correlate with positron trapping parameters (**Figure 8**). The nature of free-volume defects, where positrons are captured, is typical for all compositions.

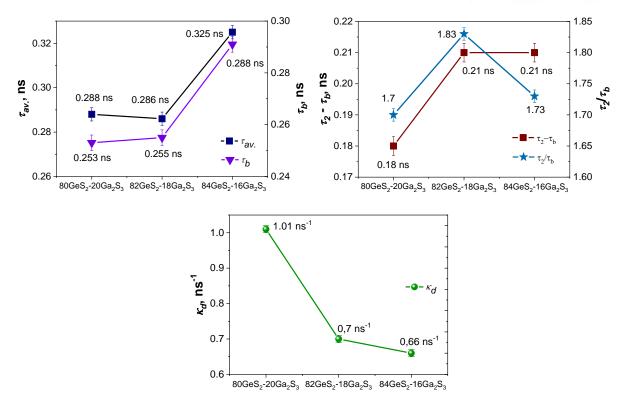


Figure 8. Dependences of positron trapping parameters for the basic GeS₂-Ga₂S₃ ChG

DRAL investigations were performed by double measurements (two points are circled in **Figure 9**). Despite only three compositions of ChG have been studied, it is difficult to draw an unambiguous conclusion about the linearity of the evolution of *S-W* parameters, but it can be argued that it is close to linear.

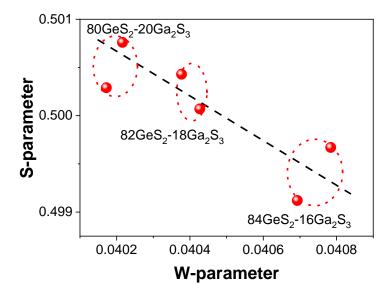


Figure 9. S-W plot for the basic GeS₂-Ga₂S₃ ChG

Thus, the grouped points of double measurements on the correlation dependence of S-W parameters are on one line from the 80GeS_2 - $20\text{Ga}_2\text{S}_3$ to 82GeS_2 - $18\text{Ga}_2\text{S}_3$ and up to 84GeS_2 - $16\text{Ga}_2\text{S}_3$ composition in the direction of decrease of S parameter and increase of W parameter. Such behavior corresponds to a so-called abnormal tendency in the κ_d - ρ correlation [41], when all defect-related components, corresponding trapping parameters and densities exhibit obvious deviations, which can be ascribed to some changes in the defect environment.

The approach considered in this work can be particularly useful for analyzing extended defect structures formed in the near-surface region of crystalline samples irradiated with fast heavy ions [45-49] or electrochemical etching [50].

4. Conclusion

Structural evolution of free-volume defects (positron trapping voids) in the Ge-Ga-S/Se chalcogenide glasses were studied on the example of the 80GeSe_2 - $20\text{Ga}_2\text{Se}_3$ glasses annealed for 10 h, 25 h and 50 h as well as the basic 80GeS_2 - $20\text{Ga}_2\text{S}_3$, 82GeS_2 - $18\text{Ga}_2\text{S}_3$ and 84GeS_2 - $16\text{Ga}_2\text{S}_3$ matrices. It is established that in the investigated ChG, two main tendencies in evolution of free-volume defect can be possible: void agglomeration and void fragmentation. Specific agglomeration of smaller voids into larger entities reveals an increase of τ_2 lifetime and decrease of τ_2 intensity. Other positron trapping parameters are in correlation with components input within two-state positron trapping model.

It is shown that initial annealing of the 80GeSe₂-20Ga₂Se₃ for 10 h results in agglomeration of free-volume defects with their further agglomeration at annealing for 25 h. At the final stage (annealing during 50 h) the shrinkage of fragmented voids is observed. It is shown that Garelated free-volume sub-system plays a decisive role in positron trapping process in the GeS₂-Ga₂S₃ glasses, while the overall density variation is defined mainly by Ge-related sub-system. These results serve as basis for new characterization route for inner free-volume structure of these glasses. It can be assumed that the void agglomeration is related with increase of GeS₂ and decrease of Ga₂S₃ content (from 80GeS₂-20Ga₂S₃ to 82GeS₂-18Ga₂S₃). Further expansion of defect-related positron trapping sites is due to transformation to the 84GeS₂-16Ga₂S₃ matrix.

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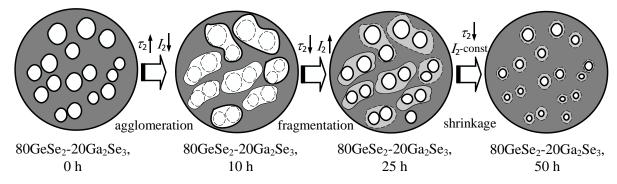
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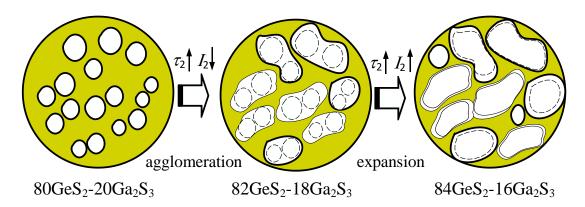
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Free-volume extended defects in structurally-modified Ge-Ga-S/Se glasses

Transformation of free-volume extended defects in the 80GeSe₂-20Ga₂Se₃ chalcogenide glasses caused by thermal annealing for 10, 25 and 50 h as well as in the GeS₂-Ga₂S₃ glasses with different GeS₂ and Ga₂S₃ contents were studied. It is shown that in the 80GeSe₂-20Ga₂Se₃ glasses agglomeration of free volumes in the initial stage of annealing with further fragmentation and shrinkage is observed. Increase content of Ge-related sub-system in the GeS₂-Ga₂S₃-based glasses results in agglomeration of defects with their further expansion.



Processes transformation of free-volume defects in the 80GeSe₂-20Ga₂Se₃ ChG during annealing



Transformation of free-volume defects in basic GeS₂-20Ga₂S₃ ChG